

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant	:	Todd <i>et al.</i>
Appl. No.	:	10/623,482
Filed	:	July 18, 2003
For	:	METHOD TO FORM ULTRA HIGH QUALITY SILICON- CONTAINING COMPOUND LAYERS
Examiner	:	Ron Everett Pompey
Group Art Unit	:	2812

AMENDMENT ACCOMPANYING REQUEST FOR CONTINUED EXAMINATION**Mail Stop RCE**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed on March 06, 2007, please amend the above-identified application as follows.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 4 of this paper.